



香港中文大學
The Chinese University of Hong Kong

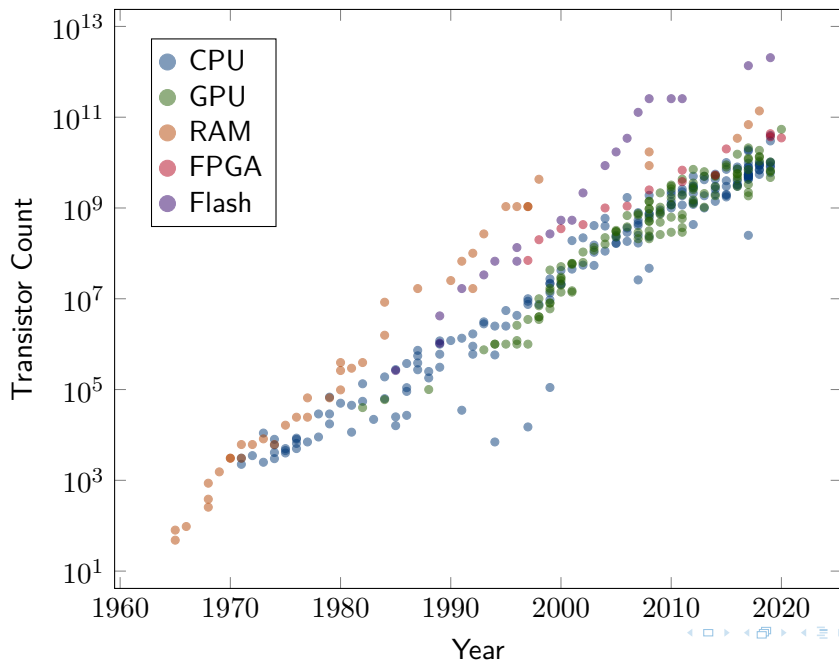
VLSI Mask Optimization: From Shallow To Deep Learning

Bei Yu

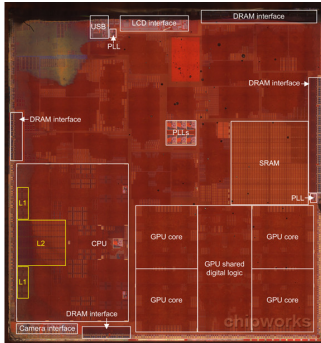
Department of Computer Science and Engineering
The Chinese University of Hong Kong



Moore's Law to Extreme Scaling

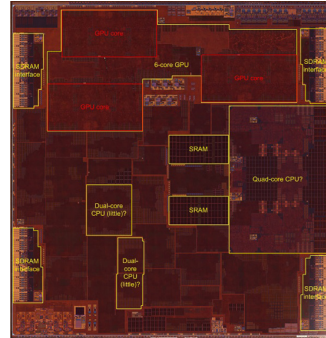


Scaling of Apple SOC



Apple A7 (2013)

- ▶ 1,000,000,000 Transistors
- ▶ $102mm^2$ die size
- ▶ 1.3GHz

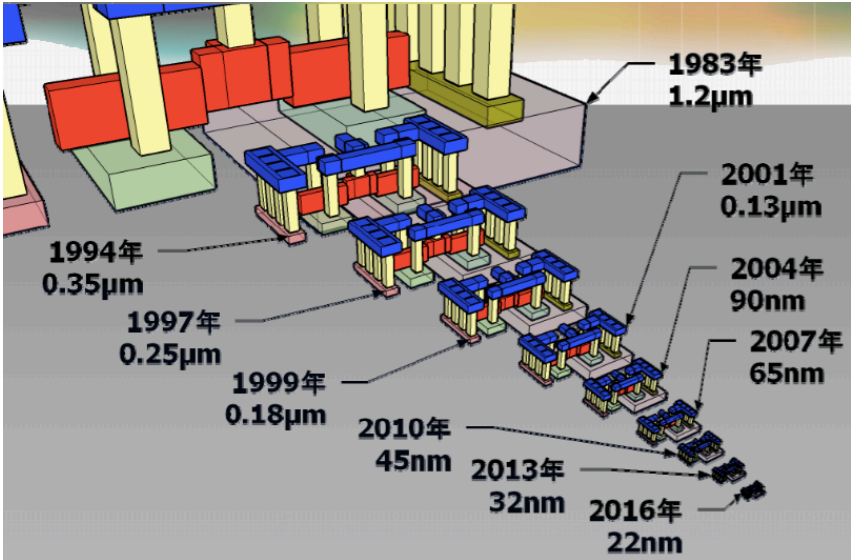


Apple A10 (2016)

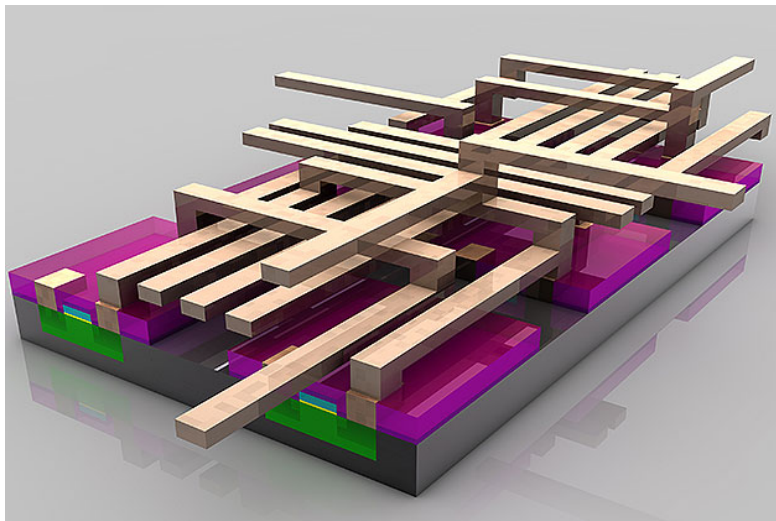
- ▶ 3,300,000,000 Transistors
- ▶ $125mm^2$ die size
- ▶ 2.34GHz



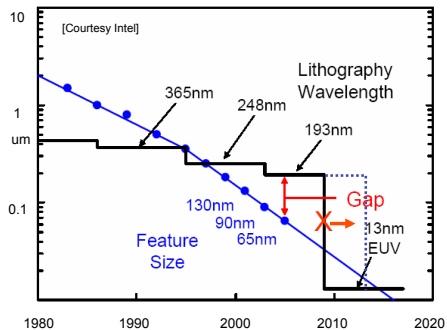
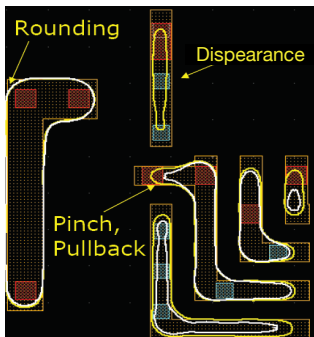
An Inverter Example



Detailed View of Layout



Manufacturing Issues of Layout



Manufacturability Status & Challenges



Mainstream Tools

Market Anually: USD 100M!

1. Calibre by Mentor Graphics
2. Brion Tool by ASML
3. IC Validator by Synopsys
4. Pegasus by Cadence

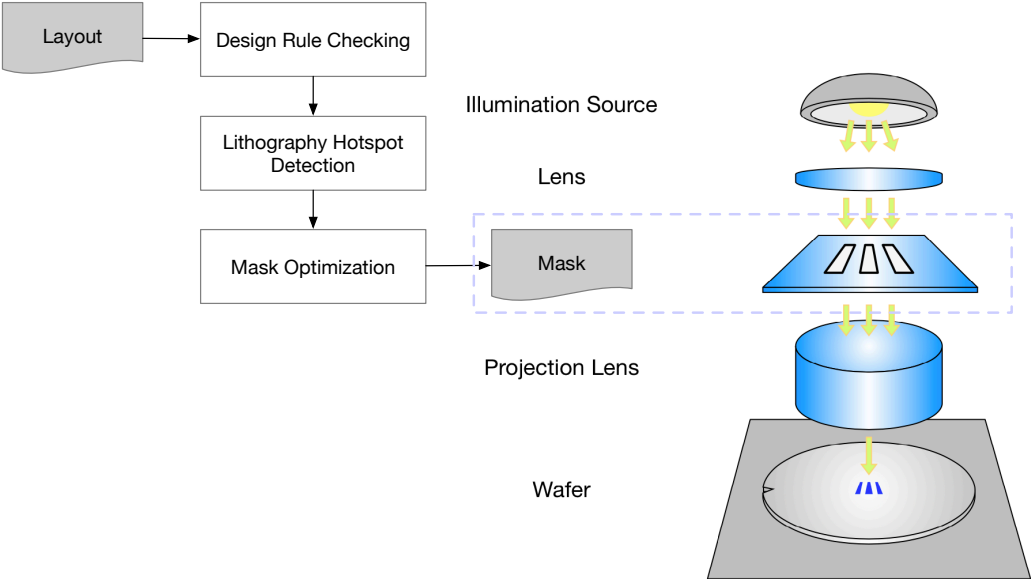
Mentor[®]
A Siemens Business

BRION
an **ASML** company

SYNOPSYS[®] **cādence**



From Layout to Chip



Outline

Task 1: Hotspot Detection

Task 2: Mask Optimization

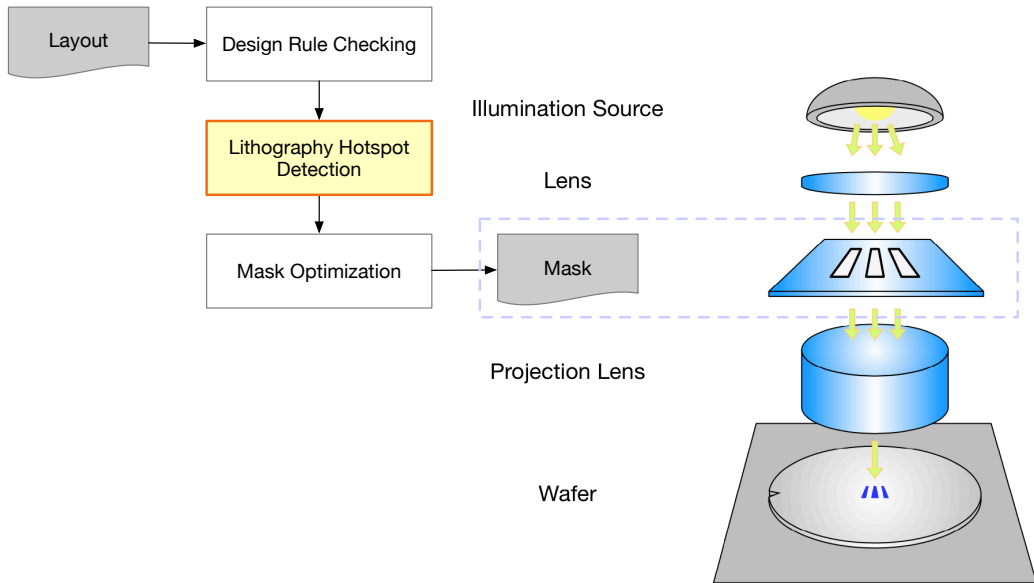


Outline

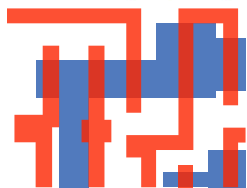
Task 1: Hotspot Detection

Task 2: Mask Optimization





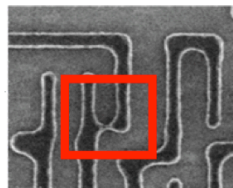
Challenge: Failure (Hotspot) Detection



Pre-OPC Layout

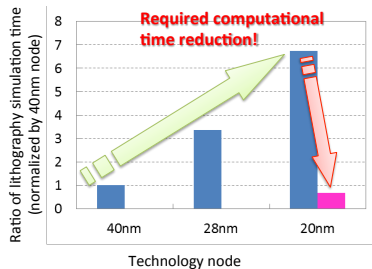


Post-OPC Mask

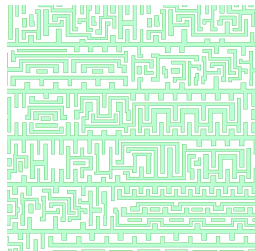
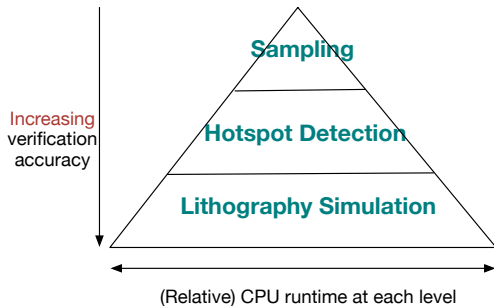


Hotspot on Wafer

- ▶ RET: OPC, SRAF, MPL
- ▶ Still hotspot: low fidelity patterns
- ▶ Simulations: extremely CPU intensive



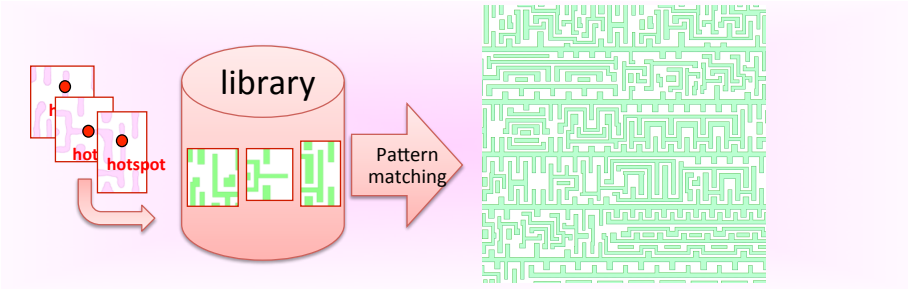
Hotspot Detection Hierarchy



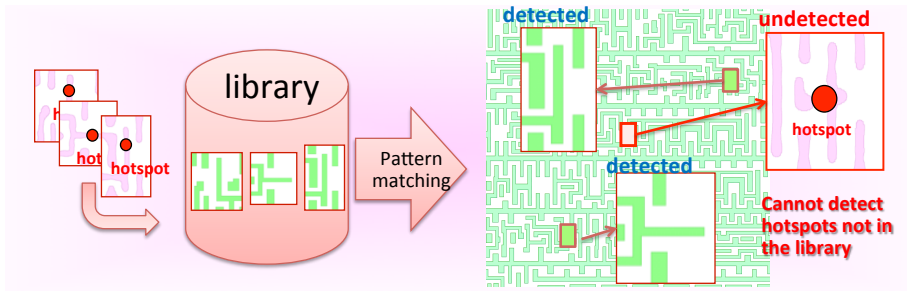
- ▶ **Sampling** (DRC Checking): scan and rule check each region
- ▶ **Hotspot Detection:** verify the sampled regions and report potential hotspots
- ▶ **Lithography Simulation:** final verification on the reported hotspots



Pattern Matching based Hotspot Detection



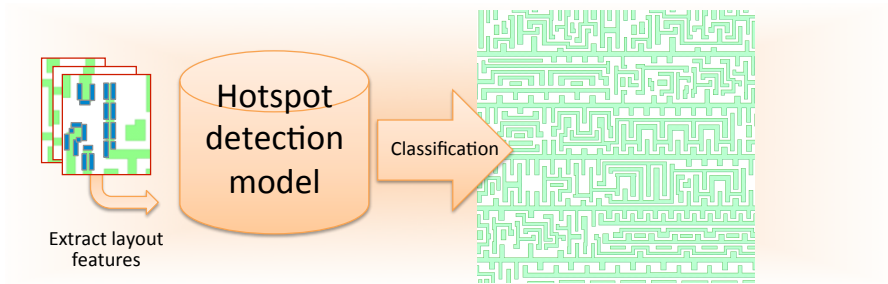
Pattern Matching based Hotspot Detection



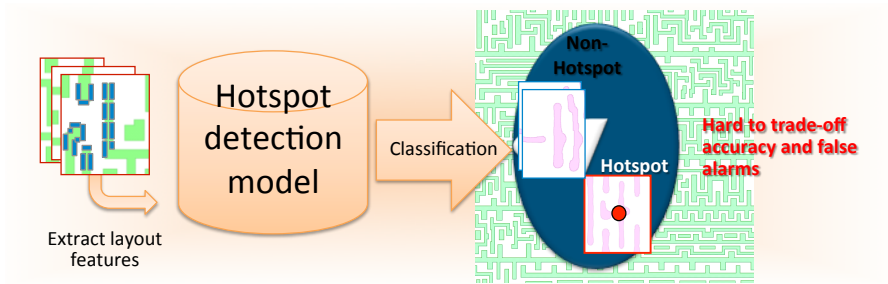
- ▶ Fast and accurate
- ▶ [Yu+, ICCAD'14] [Nosato+, JM3'14] [Su+, TCAD'15]
- ▶ Fuzzy pattern matching [Wen+, TCAD'14]
- ▶ **Hard** to detect non-seen pattern



Classification based Hotspot Detection



Classification based Hotspot Detection

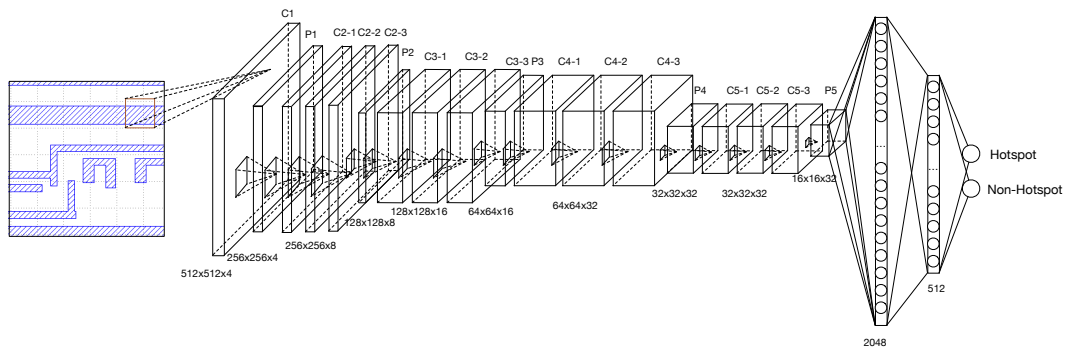


- ▶ Predict new patterns
- ▶ Decision-tree, ANN, SVM, Boosting ...
- ▶ [Drmanac+,DAC'09] [Ding+,TCAD'12] [Yu+,JM3'15] [Matsunawa+,SPIE'15] [Yu+,TCAD'15]
- ▶ **Hard** to balance accuracy and false-alarm



First DNN Hotspot Detection Architecture¹

- ▶ Total 21 layers with 13 convolution layers and 5 pooling layers.
- ▶ A ReLU is applied after each convolution layer.



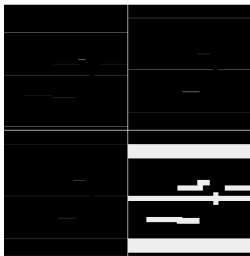
¹Haoyu Yang, Luyang Luo, et al. (2017). "Imbalance aware lithography hotspot detection: a deep learning approach". In: *JM3* 16.3, p. 033504.



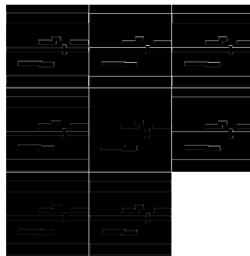
Layer Visualization



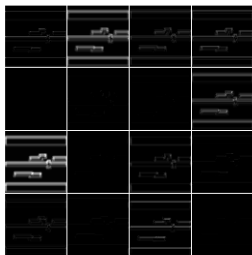
Origin



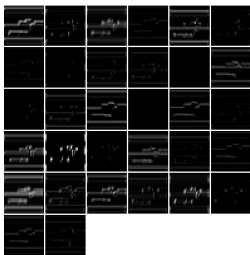
Pool1



Pool2



Pool3



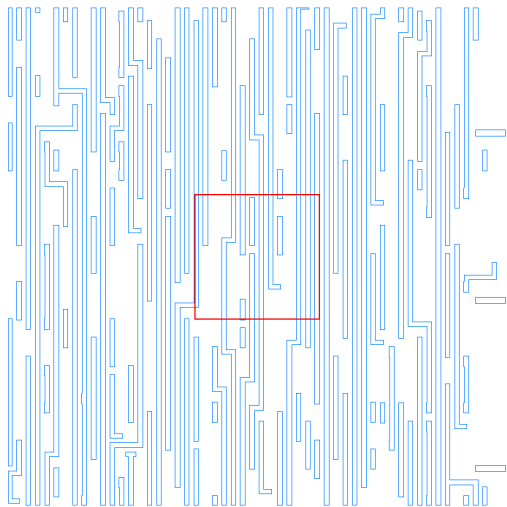
Pool4



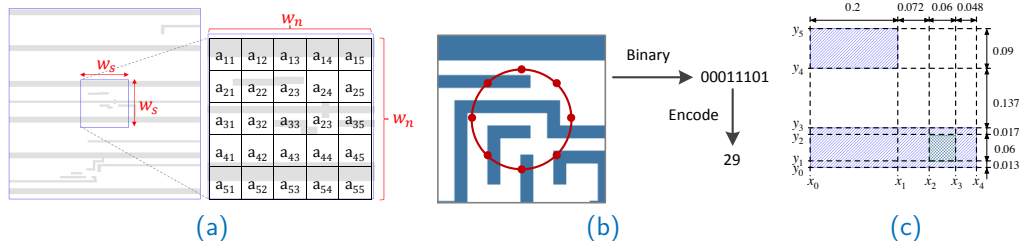
Pool5



Rethinking: “ImageHotspot” v.s. ImageNet



HSD-Research: New Representation



- ▶ (a) Density-based encoding [SPIE'15]²
- ▶ (b) Concentric circle sampling [ICCAD'16]³
- ▶ (c) Squish pattern [ASPDAC'19]⁴

²Tetsuaki Matsunawa et al. (2015). "A new lithography hotspot detection framework based on AdaBoost classifier and simplified feature extraction". In: *Proc. SPIE*. vol. 9427.

³Hang Zhang, Bei Yu, and Evangeline F. Y. Young (2016). "Enabling Online Learning in Lithography Hotspot Detection with Information-Theoretic Feature Optimization". In: *Proc. ICCAD*, 47:1–47:8.

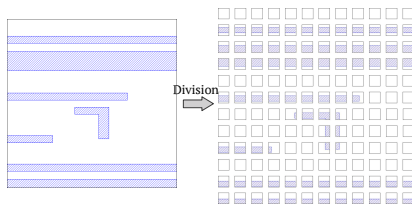
⁴Haoyu Yang, Piyush Pathak, et al. (2019). "Detecting multi-layer layout hotspots with adaptive squish patterns". In: *Proc. ASPDAC*, pp. 299–304.



Simplified CNN Architecture [DAC'17]⁵

Feature Tensor Generation:

- ▶ Clip Partition
- ▶ Discrete Cosine Transform
- ▶ Discarding High Frequency Components
- ▶ Feature Tensor



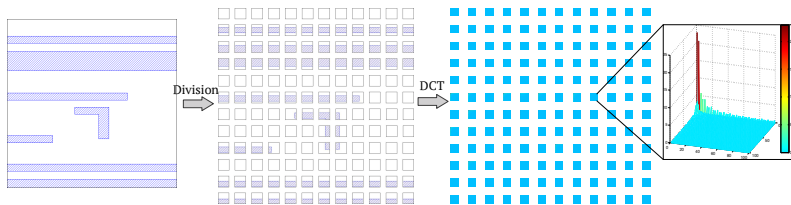
⁵Haoyu Yang, Jing Su, et al. (2017). "Layout Hotspot Detection with Feature Tensor Generation and Deep Biased Learning". In: *Proc. DAC*, 62:1–62:6.



Simplified CNN Architecture [DAC'17]⁵

Feature Tensor Generation:

- ▶ Clip Partition
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- ▶ Discarding High Frequency Components
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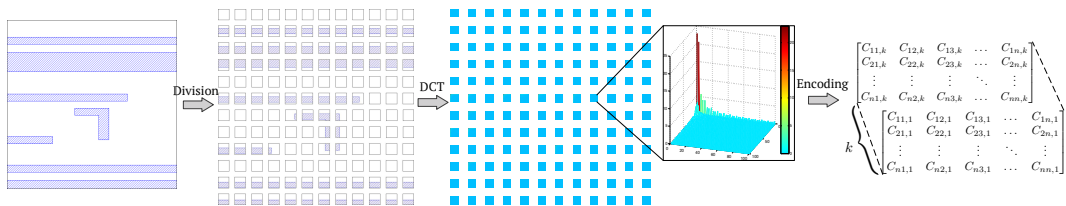
⁵Haoyu Yang, Jing Su, et al. (2017). "Layout Hotspot Detection with Feature Tensor Generation and Deep Biased Learning". In: *Proc. DAC*, 62:1–62:6.



Simplified CNN Architecture [DAC'17]⁵

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- ▶ Clip Partition
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⁵Haoyu Yang, Jing Su, et al. (2017). "Layout Hotspot Detection with Feature Tensor Generation and Deep Biased Learning". In: *Proc. DAC*, 62:1–62:6.

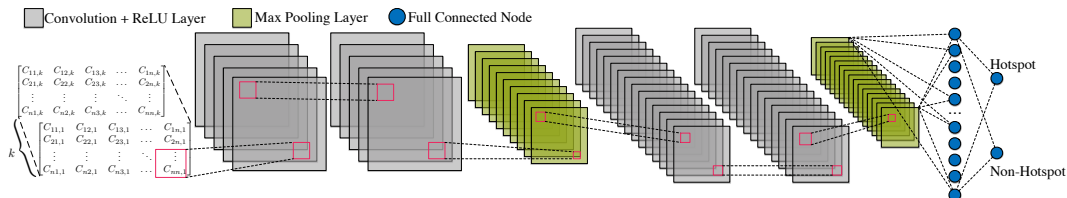


Simplified CNN Architecture [DAC'17]

Feature Tensor

- ▶ k -channel hyper-image
- ▶ Compatible with CNN
- ▶ Storage and computational efficiency

Layer	Kernel Size	Stride	Output Node #
conv1-1	3	1	$12 \times 12 \times 16$
conv1-2	3	1	$12 \times 12 \times 16$
maxpooling1	2	2	$6 \times 6 \times 16$
conv2-1	3	1	$6 \times 6 \times 32$
conv2-2	3	1	$6 \times 6 \times 32$
maxpooling2	2	2	$3 \times 3 \times 32$
fc1	N/A	N/A	250
fc2	N/A	N/A	2



The Biased Learning Algorithm

- ▶ Minimize difference with ground truths

$$y_n^* = [1, 0], \quad y_h^* = [0, 1].$$

$$F \in \begin{cases} \mathcal{N}, & \text{if } y(0) > 0.5, \\ \mathcal{H}, & \text{if } y(1) > 0.5. \end{cases}$$

- ▶ Naive: Shifting decision boundary

$$F \in \begin{cases} \mathcal{N}, & \text{if } y(0) > 0.5 + \lambda, \\ \mathcal{H}, & \text{if } y(1) > 0.5 - \lambda. \end{cases}$$



The Biased Learning Algorithm

- ▶ Minimize difference with ground truths

$$y_n^* = [1, 0], \quad y_h^* = [0, 1].$$

$$F \in \begin{cases} \mathcal{N}, & \text{if } y(0) > 0.5, \\ \mathcal{H}, & \text{if } y(1) > 0.5. \end{cases}$$

- ▶ Naive: Shifting decision boundary (✗)

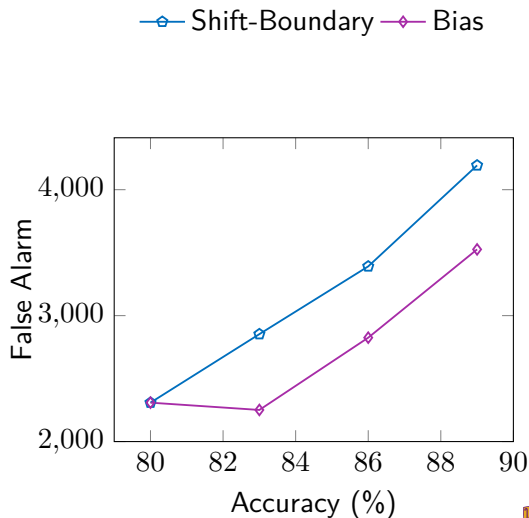
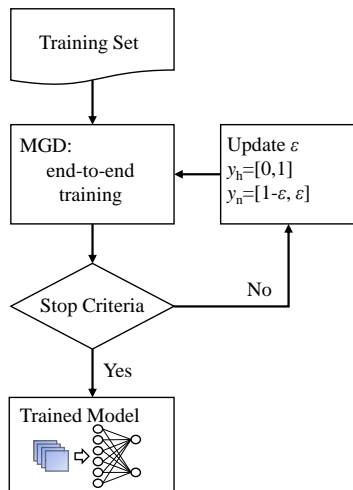
$$F \in \begin{cases} \mathcal{N}, & \text{if } y(0) > 0.5 + \lambda, \\ \mathcal{H}, & \text{if } y(1) > 0.5 - \lambda. \end{cases}$$

- ▶ Biased ground truth:

$$y_n^* = [1 - \epsilon, \epsilon].$$

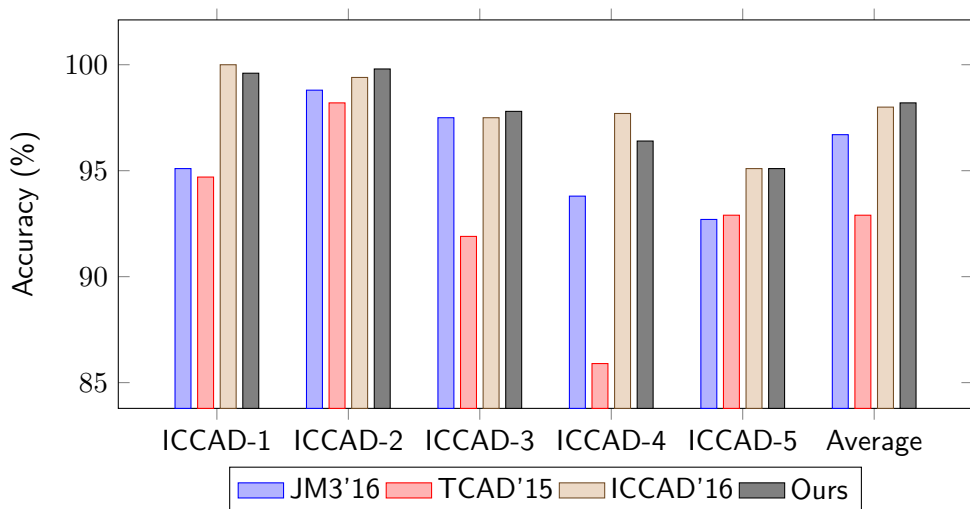


The Biased Learning Algorithm



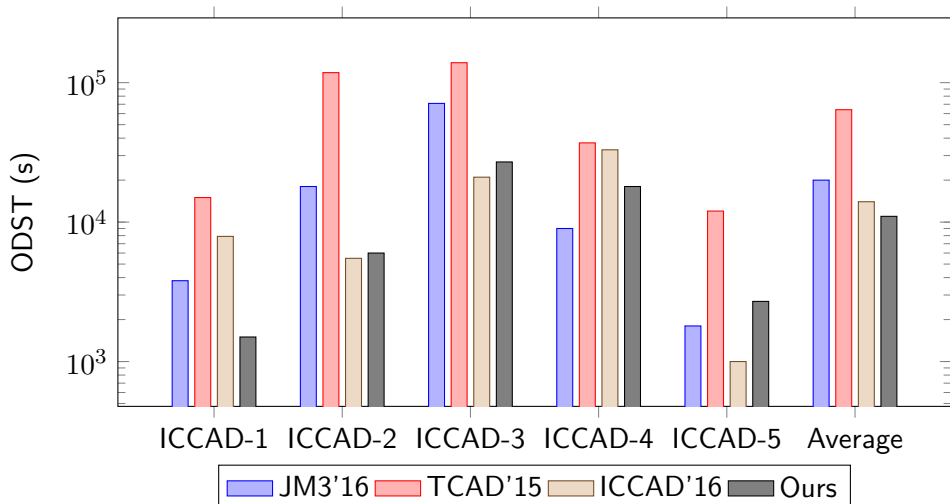
Comparison with Previous Hotspot Detectors

- Detection accuracy improved from 89.6% to 95.5%



Comparison with Previous Hotspot Detectors

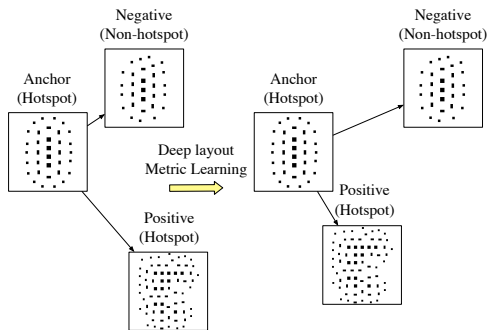
- ▶ Comparable false alarm penalty



Metric Feature Learning [ICCAD'20]⁶

Motivation

- ▶ In original space, the anchor is much similar to the negative
- ▶ After deep layout metric learning, in a new manifold, the two hotspot layout clips are kept apart from the non-hotspot clip



⁶Hao Geng, Haoyu Yang, et al. (2020). “Hotspot Detection via Attention-based Deep Layout Metric Learning”. In: *Proc. ICCAD*.

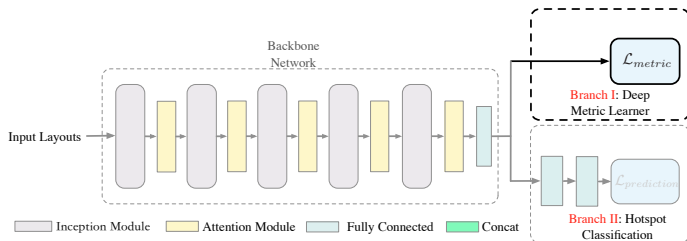


Metric Feature Learning

- ▶ A triplet: $f_w(\mathbf{x}_i)$, $f_w(\mathbf{x}_i^+)$, $f_w(\mathbf{x}_i^-)$
- ▶ $f_w(\mathbf{x}_i)$: an anchor layout clip
- ▶ $f_w(\mathbf{x}_i^+)$: sharing the same label with the anchor
- ▶ $f_w(\mathbf{x}_i^-)$: having the opposite label to the anchor

$$\min_w \frac{1}{n} \sum_{i=1}^N \max(0, M + \|f_w(\mathbf{x}_i) - f_w(\mathbf{x}_i^+)\|_2^2 - \|f_w(\mathbf{x}_i) - f_w(\mathbf{x}_i^-)\|_2^2) \quad (1)$$

$$\text{s.t. } \|f_w(\mathbf{x}_i)\|_2^2 = 1, \forall (f_w(\mathbf{x}_i), f_w(\mathbf{x}_i^+), f_w(\mathbf{x}_i^-)) \in \mathcal{T}. \quad (2)$$



Metric Feature Learning

Gradients Calculation:

$$\frac{\partial \mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-))}{\partial f_{\mathbf{w}}(\mathbf{x}_i^+)} = \frac{2}{n} (f_{\mathbf{w}}(\mathbf{x}_i^+) - f_{\mathbf{w}}(\mathbf{x}_i))$$
$$\cdot \mathbf{1} (\mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-)) > 0), \quad (3a)$$

$$\frac{\partial \mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-))}{\partial f_{\mathbf{w}}(\mathbf{x}_i^-)} = \frac{2}{n} (f_{\mathbf{w}}(\mathbf{x}_i) - f_{\mathbf{w}}(\mathbf{x}_i^-))$$
$$\cdot \mathbf{1} (\mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-)) > 0), \quad (3b)$$

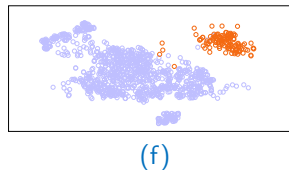
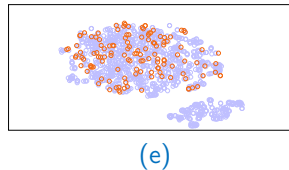
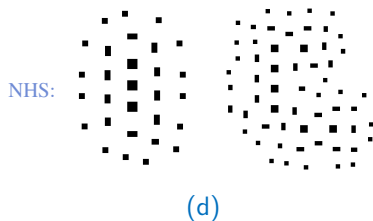
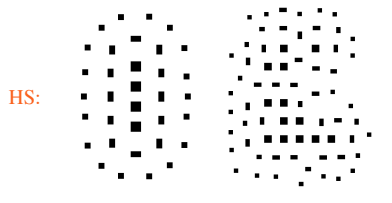
$$\frac{\partial \mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-))}{\partial f_{\mathbf{w}}(\mathbf{x}_i)} = \frac{2}{n} (f_{\mathbf{w}}(\mathbf{x}_i^-) - f_{\mathbf{w}}(\mathbf{x}_i^+))$$
$$\cdot \mathbf{1} (\mathcal{L}_{metric}(f_{\mathbf{w}}(\mathbf{x}_i), f_{\mathbf{w}}(\mathbf{x}_i^+), f_{\mathbf{w}}(\mathbf{x}_i^-)) > 0), \quad (3c)$$

where $\mathbf{1}$ is the indicator function which is defined as:

$$\mathbf{1}(x) = \begin{cases} 1 & \text{if } x \text{ is true,} \\ 0 & \text{otherwise.} \end{cases} \quad (3d)$$



The t-SNE visualizations of feature embeddings on VIA benchmarks

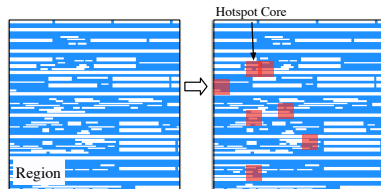


(a) The exemplars of hotspots and non-hotspots; (b) The DCT feature embeddings of TCAD'19; (c) The feature embeddings of our proposed framework.

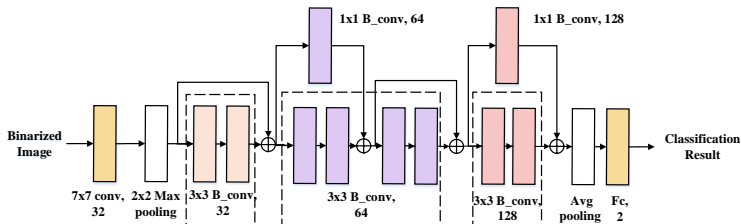


HSD-Research: New Network Architecture

- ▶ Region-based HSD [DAC'19]⁷



- ▶ Binarized residual neural network [DAC'19]⁸



⁷Ran Chen et al. (2019). "Faster Region-based Hotspot Detection". In: *Proc. DAC*, 146:1–146:6.

⁸Yiyang Jiang et al. (2019). "Efficient Layout Hotspot Detection via Binarized Residual Neural Network". In: *Proc. DAC*, 147:1–147:6.

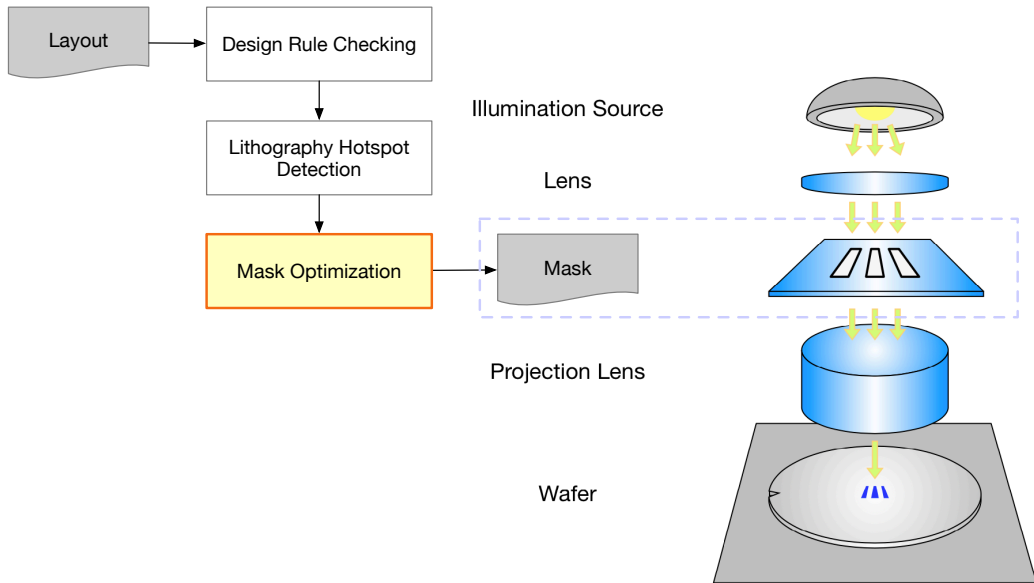


Outline

Task 1: Hotspot Detection

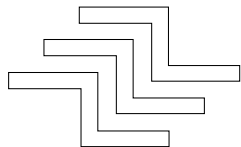
Task 2: Mask Optimization



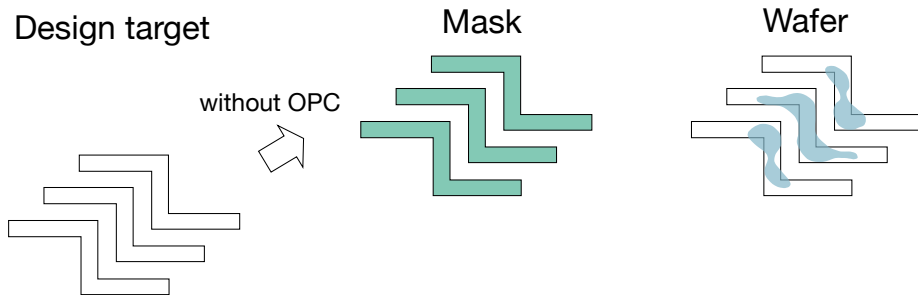


Mask Optimization

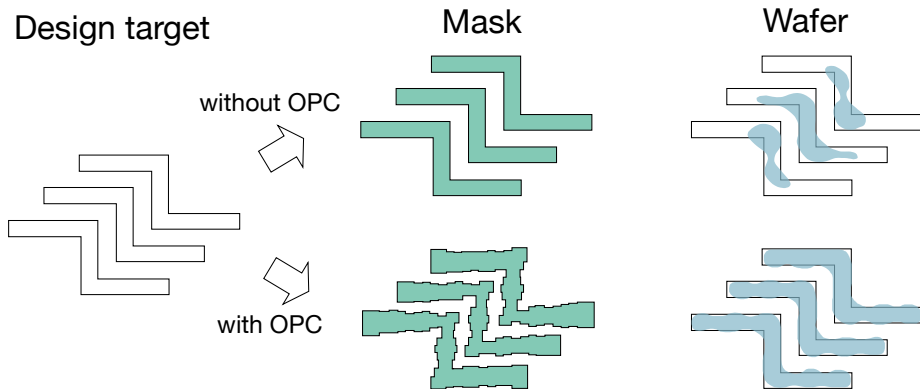
Design target



Mask Optimization



Mask Optimization



Lithography Model

- ▶ SVD Approximation of Partial Coherent System [Cobb,1998]

$$I = \sum_{k=1}^{N^2} w_k |M \otimes h_k|^2. \quad (4)$$

- ▶ Reduced Model [Gao+,DAC'14]

$$I = \sum_{k=1}^{N_h} w_k |M \otimes h_k|^2. \quad (5)$$

- ▶ Etch Model

$$Z(x, y) = \begin{cases} 1, & \text{if } I(x, y) \geq I_{th}, \\ 0, & \text{if } I(x, y) < I_{th}. \end{cases} \quad (6)$$



Inverse Lithography Technique (ILT)

The main objective in ILT is minimizing the lithography error through gradient descent.

$$E = \|Z_t - Z\|_2^2, \quad (7)$$

where Z_t is the target and Z is the wafer image of a given mask.

Apply translated sigmoid functions to make the pixel values close to either 0 or 1.

$$Z = \frac{1}{1 + \exp[-\alpha \times (I - I_{th})]}, \quad (8)$$

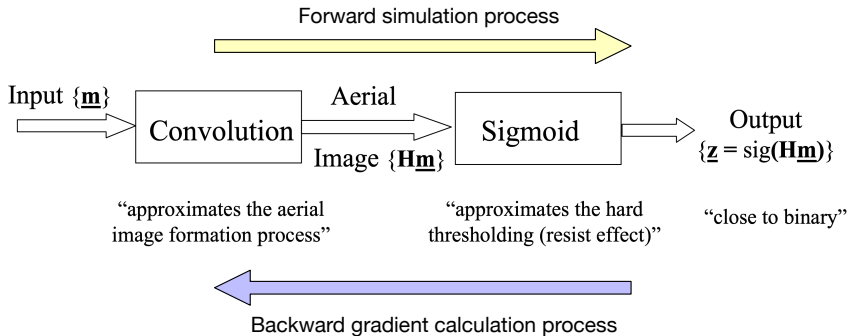
$$M_b = \frac{1}{1 + \exp(-\beta \times M)}. \quad (9)$$

Combine Equations (4)–(9) and the analysis in [Poonawala,TIP'07],

$$\begin{aligned} \frac{\partial E}{\partial M} = & 2\alpha\beta \times M_b \odot (1 - M_b) \odot \\ & (((Z - Z_t) \odot Z \odot (1 - Z) \odot (M_b \otimes H^*)) \otimes H + \\ & ((Z - Z_t) \odot Z \odot (1 - Z) \odot (M_b \otimes H)) \otimes H^*). \end{aligned} \quad (10)$$

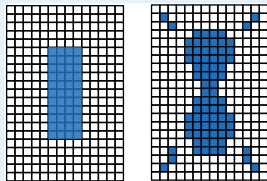


ILT flow



Typical ILT

- ▶ Mask \rightarrow Image \rightarrow Matrix
- ▶ Calculate gradient on each pixel.



Level-set method

- ▶ Boundary-based update
- ▶ Implicit representation; focus on boundaries

$$\begin{cases} \phi(t, \mathbf{x}) < 0 & \text{if } \mathbf{x} \in \Omega(t) \\ \phi(t, \mathbf{x}) = 0 & \text{if } \mathbf{x} \in \Gamma(t) \\ \phi(t, \mathbf{x}) > 0 & \text{if } \mathbf{x} \in \overline{\Omega(t)} \end{cases}$$

⁹Jhuh-Rong Gao et al. (2014). "MOSAIC: Mask Optimizing Solution With Process Window Aware Inverse Correction". In: *Proc. DAC. San Jose, California*, 52:1–52:6.

¹⁰Yuzhe Ma et al. (2017). "A Unified Framework for Simultaneous Layout Decomposition and Mask Optimization". In: *Proc. ICCAD*, pp. 81–88.

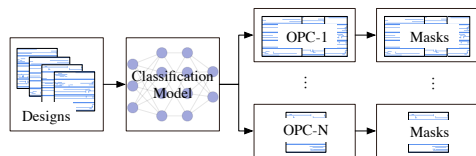
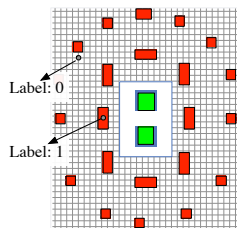
¹¹Ziyang Yu et al. (2021). "A GPU-enabled Level Set Method for Mask Optimization". In: *submitted to DATE*.



Learning-based Mask Optimization

Discriminative models [TCAD'20]¹² [ASPDAC'20]¹³

- ▶ Pixel-wise classification
- ▶ Printed image estimation/quality estimation



¹²Hao Geng, Wei Zhong, et al. (2020). "SRAF Insertion via Supervised Dictionary Learning". In: *IEEE TCAD*.

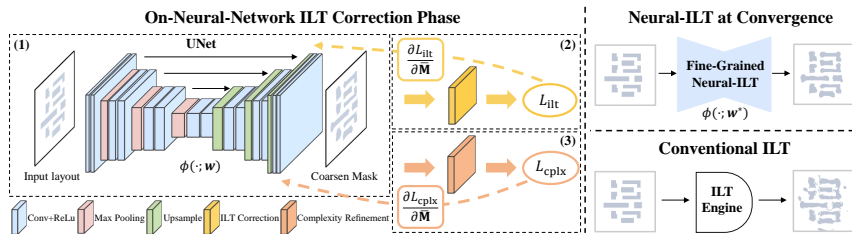
¹³Haoyu Yang, Wei Zhong, et al. (2020). "VLSI Mask Optimization: From Shallow To Deep Learning". In: *Proc. ASPDAC*, pp. 434–439.



Learning-based Mask Optimization

Generative model¹⁴¹⁵¹⁶

► Image generation



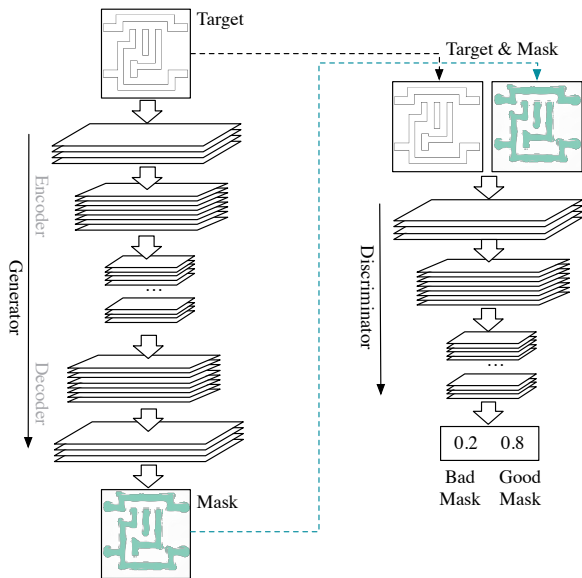
¹⁴Haoyu Yang, Shuhe Li, et al. (2018). "GAN-OPC: Mask Optimization with Lithography-guided Generative Adversarial Nets". In: *Proc. DAC*, 131:1–131:6.

¹⁵Bentian Jiang et al. (2020). "Neural-ILT: Migrating ILT to Neural Networks for Mask Printability and Complexity Co-optimization". In: *Proc. ICCAD*.

¹⁶Guojin Chen et al. (2020). "DAMO: Deep Agile Mask Optimization for Full Chip Scale". In: *Proc. ICCAD*.



GAN-OPC [DAC'18]¹⁷



¹⁷Haoyu Yang, Shuhe Li, et al. (2018). "GAN-OPC: Mask Optimization with Lithography-guided Generative Adversarial Nets". In: *Proc. DAC*, 131:1–131:6.



GAN Training

Based on the OPC-oriented GAN architecture in our framework, we tweak the objectives of G and D accordingly,

$$\max_G \mathbb{E}_{Z_t \sim \mathcal{Z}} [\log(D(Z_t, G(Z_t)))], \quad (11)$$

$$\max_D \mathbb{E}_{Z_t \sim \mathcal{Z}} [\log(D(Z_t, M^*))] + \mathbb{E}_{Z_t \sim \mathcal{Z}} [1 - \log(D(Z_t, G(Z_t)))]. \quad (12)$$

In addition to facilitate the training procedure, we minimize the differences between generated masks and reference masks when updating the generator as in Equation (13).

$$\min_G \mathbb{E}_{Z_t \sim \mathcal{Z}} \|M^* - G(Z_t)\|_n, \quad (13)$$

where $\|\cdot\|_n$ denotes the l_n norm.



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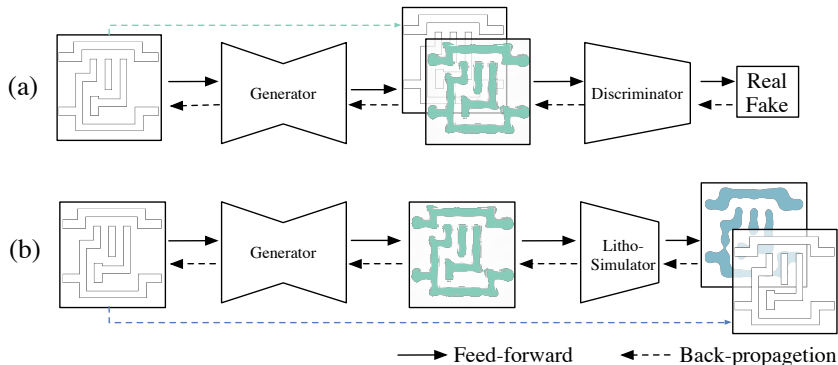
where $\|\cdot\|_n$ denotes the l_n norm. Combining (11), (12) and (13), the objective of our GAN model becomes

$$\min_G \max_D \mathbb{E}_{Z_t \sim \mathcal{Z}} [1 - \log(D(Z_t, G(Z_t))) + \|M^* - G(Z_t)\|_n^n + \mathbb{E}_{Z_t \sim \mathcal{Z}} [\log(D(Z_t, M^*))]]. \quad (14)$$

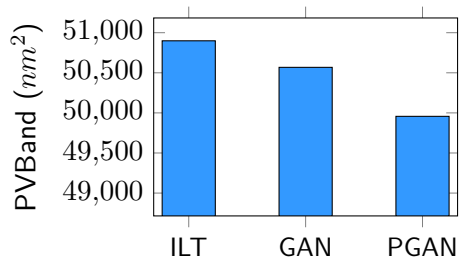


ILT-guided Pre-training

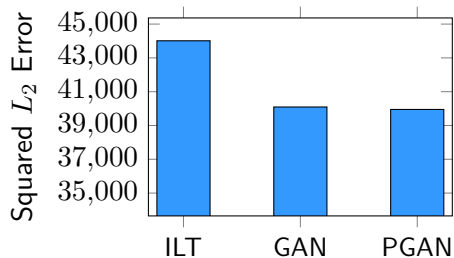
Observing that both ILT and neural network optimization share similar gradient descent procedure, we propose a joint training algorithm that takes advantages of ILT engine, as depicted in Figure (b). We initialize the generator with lithography-guided pre-training to make it converge well in the GAN optimization flow thereafter.



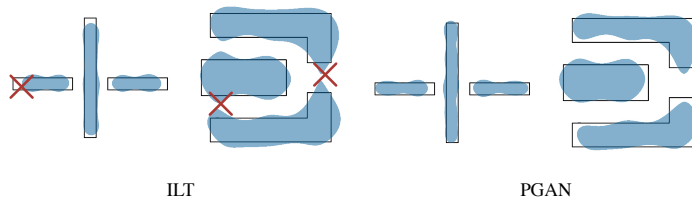
Results



(a)



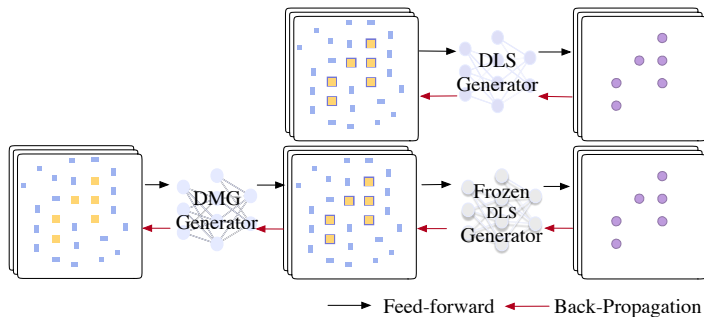
(b)



(c)



Deep Mask Optimization [ICCAD'20]¹⁸



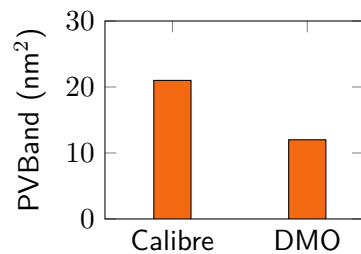
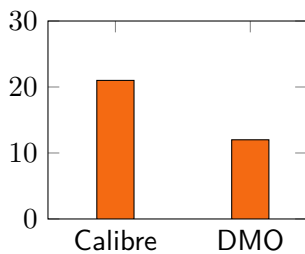
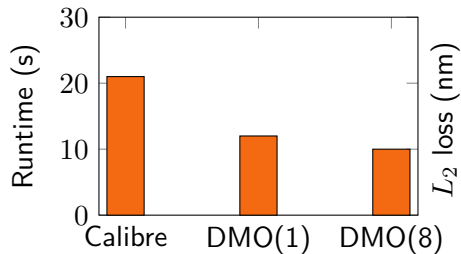
	GAN-OPC			Calibre			DMO		
	L_2 (nm)	PV Band (nm ²)	Runtime (s)	L_2 (nm)	PV Band (nm ²)	Runtime (s)	L_2 (nm)	PV Band (nm ²)	Runtime (s)
case 1	7456	11424	284	5159	11671	1417	4631	11166	352
case 2	7321	11215	281	4987	11463	1406	4432	10955	336
case 3	7102	11265	285	5420	11516	1435	4802	11032	367
case 4	8032	11642	322	5382	11910	1606	4835	11265	399
Average	7478	11386	293	5237	11640	1466	4675	11104	363
Ratio	1.60	1.03	0.80	1.12	1.05	4.04	1.00	1.00	1.00

¹⁸Guojin Chen et al. (2020). “DAMO: Deep Agile Mask Optimization for Full Chip Scale”. In: *Proc. ICCAD*.



Scalability on Full-chip Layout

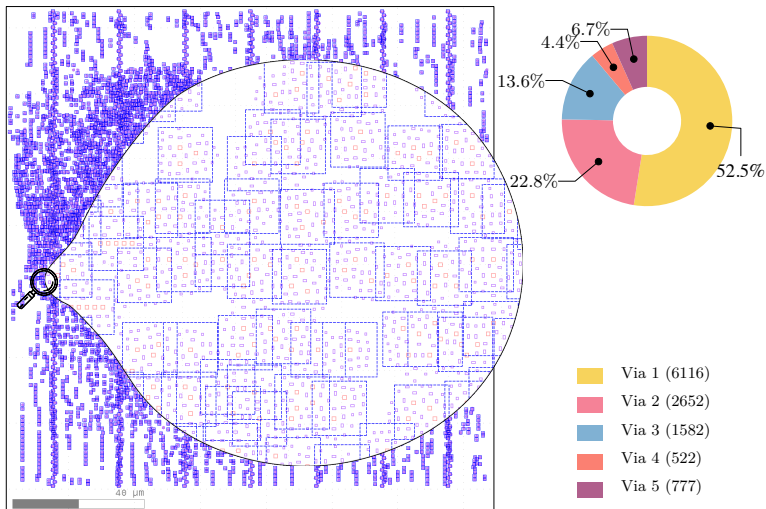
► Tested on $10\mu\text{m} \times 10\mu\text{m}$ layout.



- DMO(1) – Single GPU card;
- DMO(8) – 8 GPU cards



Results on ISPD 2019 datasets



Thank You!

